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(71) Applicant (for all designated States except US):
JANSSEN PHARMACEUTICA N.V. [BE/BE]; Turnhoutseweg 30, B-2340 Beerse (BE).

(71) Applicant (for US only): ARTS, Frank, Xavier, Jozef, Herwig (legal representative of the deceased inventor) [BE/BE]; Voshollei 36, B-2390 Brasschaat (BE).

(72) Inventor: JANSSEN, Paul, Adriaan, Jan (deceased).

(72) Inventors; and

(75) Inventors/Applicants (for US only): LEWI, Paulus, Joannes [BE/BE]; c/o Janssen Pharmaceutica N.V., Turnhoutseweg 30, B-2340 Beerse (BE). DE JONGE, Marc, René [NL/NL]; c/o Janssen Pharmaceutica N.V., Turnhoutseweg 30, B-2340 Beerse (BE). KOYMANS, Lucien, Maria, Henricus [NL/BE]; c/o Janssen Pharmaceutica N.V., Turnhoutseweg 30, B-2340 Beerse (BE). DAEYAERT, Frederik, Frans, Desiré [BE/BE]; c/o Janssen Pharmaceutica N.V., Turnhoutseweg 30, B-2340 Beerse (BE). HEERES, Jan [NL/BE]; c/o Janssen Pharmaceutica N.V., Turnhoutseweg 30, B-2340 Beerse (BE). VINKERS, Hendrik, Maarten [NL/BE]; c/o Janssen Pharmaceutica N.V., Turnhoutseweg 30, B-2340 Beerse

(BE). LEENDERS, Ruben, Gerardus, George [NL/NL]; c/o Mercachem, Toernooiveld 100, NL-6503 CB Nijmegen (NL). VANDENPUT, Dirk, Alfons, Leo [NL/NL]; c/o Mercachem, Toernooiveld 100, NL-6503 CB Nijmegen (NL).

(74) Common Representative: JANSSEN PHARMACEUTICA N.V.; Turnhoutseweg 30, B-2340 Beerse (BE).

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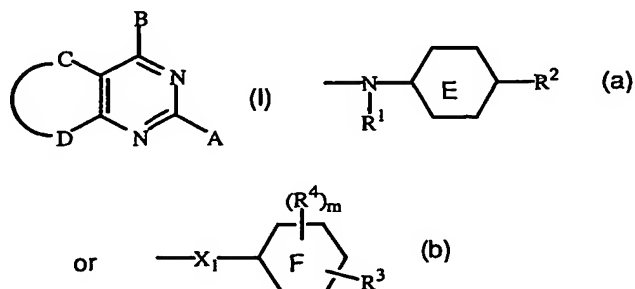
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(54) Title: HIV REPLICATION INHIBITING PURINE DERIVATIVES



(57) Abstract: The present invention relates to the use of a compound of formula (I) for the manufacture of a medicament for the prevention or the treatment of HIV infection wherein the compound of formula (I) is a compound of formula (I) a *N*-oxide, a pharmaceutically acceptable addition salt, a quaternary amine or a stereochemically isomeric form thereof, wherein A and B each represents a radical of formula (a) or (b) and wherein -C-D- represents a bivalent radical of formula -N=CH-NR¹⁷- (c-1); or -NR¹⁷-CH=N- (c-2); provided that when A represents a radical of formula (a) then B represents a radical of formula (b) and when A represents a radical of formula (b) then B represents a radical of formula (a).



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